

FINE MADE MICROELECTRONICS GROUP CO., LTD.

**8205LA** (文件编号: S&CIC2214)

20V N 沟道增强型 MOS 场效应管

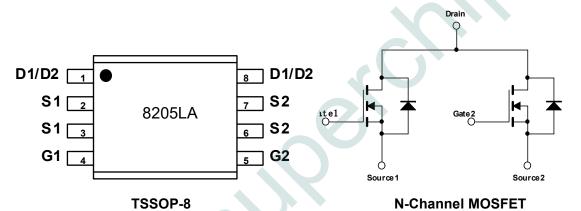
#### 20V N-Channel Enhancement-Mode MOSFET

RDS(ON), Vgs@2.5V, Ids@3.0A =  $26m\Omega$  RDS(ON), Vgs@4.0V, Ids@4.0A =  $23m\Omega$ 

RDS(ON), Vgs@4.5V, Ids@4.5A =  $22m\Omega$ 

#### 特点

- > 专有的先进平面技术
- ▶ 高密度超低电阻设计
- ▶ 大功率、大电流应用
- ▶ 理想的锂电池应用
- ▶ 封装形式: TSSOP-8



## 最大额定值和热特性 (Ta = 25℃,除非另有说明。)

<del>5</del>	<b>参数</b>	符号	值	单位	
漏源电压		V <sub>DS</sub>	20	V	
栅源电压		V <sub>GS</sub>	±12	\ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \	
漏极电流		I <sub>D</sub>	6	A	
漏极脉冲电流		I <sub>DM</sub>	20		
最大功耗	TA = 25℃	D.	1.98	W	
取入切札	TA = 75℃	$P_{D}$	1.30		
工作结温和存储温度范围		T <sub>J</sub> , T <sub>stg</sub>	-55 to 150	$^{\circ}$	
结环热阻(PCB 安装)		R <sub>0JA</sub>	61.4	°C/W	

注: 重复性极限值: 脉冲宽度由最高结温限制。 贴片时回流焊炉温请控制在 265℃以下。



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#### 电特性

参数	符号	测试条件	最小	典型	最大	单位	
静电							
漏源击穿电压	BV <sub>DSS</sub>	V <sub>GS</sub> = 0V, I <sub>D</sub> = 250uA	20			V	
		V <sub>GS</sub> = 2.5V,I <sub>D</sub> = 3.0A		26.0	29.0		
漏源导通内阻	R <sub>DS</sub> (on)	$V_{GS} = 4.0V, I_D = 4.0A$		23.0	26.0 mΩ		
		$V_{GS} = 4.5V, I_D = 4.5A$		22.0	24.0		
栅极阈值电压	V <sub>GS</sub> (th)	$V_{DS} = V_{GS}$ , $I_D = 250$ uA	0.5	0.75	0.95	V	
栅源短路时漏极电流	I <sub>DSS</sub>	V <sub>DS</sub> = 20V, V <sub>GS</sub> = 0V			1	uA	
漏极短路时截止栅电流	I <sub>GSS</sub>	V <sub>GS</sub> = ±12V, I <sub>D</sub> =0uA			±100	nA	
跨导	<b>g</b> fs	$V_{DS} = 15V, I_D = 6.0A$		25		S	
动态							
总栅极电荷	Qg			7.49	8.50	nC	
栅源电荷	Qgs	$V_{DS} = 10V, I_{D} = 6A$ $V_{GS} = 4.5V$		2.48	2.96		
栅漏电荷	Q <sub>gd</sub>			2.04	2.65		
延迟时间(On)	t <sub>d(on)</sub>			17.5	29.8		
上升时间(On)	tr	$V_{DD} = 10V, I_{D} = 6A$		28.5	38.2	ns	
延迟时间(Off)	t <sub>d(off)</sub>	$I_D = 1A, V_{GS} = 4.5V$		41.2	59.6		
下降时间(Off)	t <sub>f</sub>			10.4	26.3		
输入电容	C <sub>iss</sub>			550			
输出电容	Coss	$V_{DS} = 10V$ , $V_{GS} = 0V$ f=1.0MHz		58		pF	
反向传输电容	C <sub>rss</sub>			51			
漏源二极管							
二极管最大正向电流	Is				2.0	Α	
二极管正向电压	V <sub>SD</sub>	I <sub>S</sub> = 1.7A, V <sub>GS</sub> = 0V			1.2	V	
		·					

注:脉冲测试:脉冲宽度<=300us,占空比<=2%



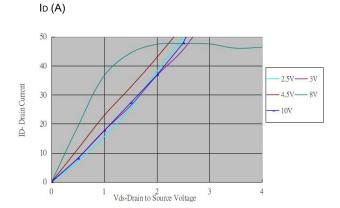
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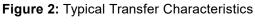
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### **Typical Performance Characteristics**

Figure1: Output Characteristics





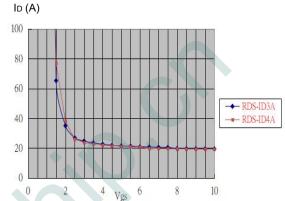


Figure 3:On-resistance vs. Drain Current

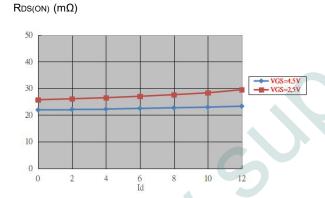


Figure 4: Body Diode Characteristics

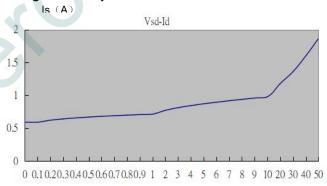
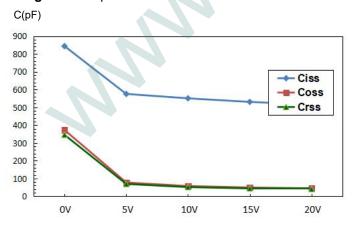


Figure 5: Capacitance Characteristics

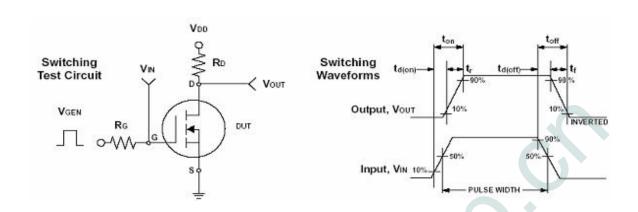




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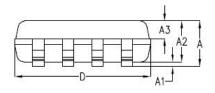
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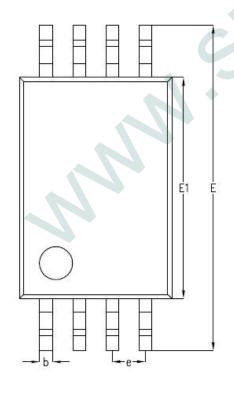


#### 封装信息

TSSOP-8







SYMBOL	MILLIMETER				
013.12.02_	MIN	NOM	MAX		
A	-	1.00	1. 10		
A1	=	0. 10	0.15		
A2	0.85	0. 90	0.95		
A3	0.35	0. 38	0.41		
b	0. 20	0. 25	0.30		
С	0.08	0. 13	0.18		
D	2. 95	3. 00	3. 05		
Е	6. 30	6. 40	6. 50		
E1	4. 35	4. 40	4. 45		
е	0. 65BSC				
L	0. 95	1. 00	1.05		
L1	0. 60BSC				
9	0°	4°	8°		